

**S arch Notes**

Application No.

10/635,803

Examiner

D. Rutledge

Applicant(s)

OKUBO ET AL.

Art Unit

2851

**SEARCHED**

Class	Subclass	Date	Examiner
355	53	5/6/2004	DR
118	52,319	5/6/2004	DR
430	5,31	5/6/2004	DR
414	935, 940	5/6/2004	DR
414	416.01	5/6/2004	DR
414	217.1	5/6/2004	DR
206	710,723	5/6/2004	DR

**INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
reticle, mask, pod, hold\$3, support\$3, base, cover, lid, top, block, rest, three, equal, equi, distanct, distance, compliant	5/6/2004	DR
triangul\$4, elastic\$4, resilient\$2, interior, mounted, located, pressure, pressing, ring, shap\$2, contact\$3, touch\$3, spring	5/6/2004	DR